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PATENT

Attorney Docket No.: ZON-001

REPLY UNDER 37. C.F.R. §1.116  
EXPEDITED PROCEDURE  
GROUP ART UNIT 1753

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS: Chistyakov  
SERIAL NO.: 10/065,277 GROUP NO.: 1753  
FILING DATE: September 30, 2002 EXAMINER: Rodney G. McDonald  
TITLE: High-Power Pulsed Magnetron Sputtering

Mail Stop AF  
Commissioner of Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Amendment and Response After Final

Sir:

The following remarks are responsive to the final Office Action mailed on January 11, 2006 in the above-identified patent application. Consideration of the following remarks, and allowance of the claims, as presented, is respectfully requested. This Amendment and Response is a reply under 37 C.F.R. §1.116. Expedited procedures are requested.

Amendments to the Claims begin on page 2 of this paper.

Remarks are on page 9 of this paper.